



United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/873,580	06/04/2001	Harumitsu Fujita	P/2171-196	5456	
2352	7590 06/05/2002				
OSTROLENK FABER GERB & SOFFEN			EXAMINER		
1180 AVEN NEW YORF	UE OF THE AMERICAS K, NY 100368403	TOLEDO, FERNANDO L			
			ART UNIT	PAPER NUMBER	
			2823		
			DATE MAIL ED: 06/05/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

		_
	Application No.	Applicant(s)
Office Action Commons	09/873,580	FUJITA, HARUMITSU
Office Action Summary	Examin r	Art Unit
	Fernando Toledo	2823
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet wi	th the correspond nce address
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 Cf after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory p - Failure to reply within the set or extended period for reply will, by s - Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b). Status	ON. FR 1.136(a). In no event, however, may a ron. In no event, however, may a ron. In reply within the statutory minimum of thirt eriod will apply and will expire SIX (6) MON statute, cause the application to become AB	eply be timely filed by (30) days will be considered timely. THS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).
1) Responsive to communication(s) filed on	12 March 2002 .	
2a)⊠ This action is FINAL . 2b)□	This action is non-final.	
3) Since this application is in condition for a closed in accordance with the practice ur		
Disposition of Claims		
4)⊠ Claim(s) <u>1,2,5 and 6</u> is/are pending in the		
4a) Of the above claim(s) is/are with	ndrawn from consideration.	
5) Claim(s) is/are allowed.		•
6)⊠ Claim(s) <u>1,2,5 and 6</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction a Application Papers	nd/or election requirement.	
9)☐ The specification is objected to by the Exar	niner	
10) ☐ The drawing(s) filed on <u>04 June 2001</u> is/are		to by the Examiner
Applicant may not request that any objection		-
11)☐ The proposed drawing correction filed on _	,	, ,
If approved, corrected drawings are required	in reply to this Office action.	
12) ☐ The oath or declaration is objected to by the	e Examiner.	
Priority under 35 U.S.C. §§ 119 and 120		
13) Acknowledgment is made of a claim for fo	reign priority under 35 U.S.C. {	§ 119(a)-(d) or (f).
a)⊠ All b) Some * c) None of:		
1. Certified copies of the priority document	nents have been received.	•
2. Certified copies of the priority docum	nents have been received in A	pplication No. <u><i>09/021,519</i></u> .
3. Copies of the certified copies of the application from the Internationa* See the attached detailed Office action for a	I Bureau (PCT Rule 17.2(a)).	•
14) Acknowledgment is made of a claim for don	nestic priority under 35 U.S.C.	§ 119(e) (to a provisional application)
a) ☐ The translation of the foreign language 15)☐ Acknowledgment is made of a claim for don	• • • • • • • • • • • • • • • • • • • •	
Attachment(s)		

U.S. Patent and Trademark Office PTO-326 (Rev. 04-01)

Notice of References Cited (PTO-892)
 Notice of Draftsperson's Patent Drawing Review (PTO-948)

3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)

6) Other:

 Art Unit: 2823

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 1. Claims 1, 2, 5 and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tigelaar et al. (U. S. patent 5,595,922) in view of Kuroda (U. S. patent 6,093,950).

In re claim 1; Tigelaar in the U. S. patent 5,595,922; figures 1-5 and related text, shows providing a semiconductor substrate 14 having several active regions of a first conductivity type (column 2); forming a gate oxide layer 18 having a first thickness onto the several active regions (figure 1); forming an electrode layer 20 onto the gate oxide layer (figure 1); pattering the electrode layer to form a gate electrode onto each of the several active regions (figure 2); oxidizing a sidewall of the gate electrode to form on the oxide layer a second thickness greater than the first thickness with the first gate oxide films, and gradually decrease from the sidewall of the gate electrode towards the centre portion thereof (figures 3-4); forming spacers on the sidewall of the gate electrode (figure 5, step 522).

Tigelaar does not disclose masking a portion of the several active regions and doping an unmasked portion of the several of active regions at a second concentration higher than the first concentration with an impurity of the second conductivity type to

Application/Control Number: 09/873,580

Art Unit: 2823

form a second transistor driven at a second voltage level lower than the first voltage level.

However, Kuroda in the U. S. patent 6,093,950; figures 1 – 26 and related text; discloses masking a portion of the several of the active regions (figures 4 and 7) and doping an unmasked region of the several of active regions at a second concentration higher than the first concentration with an impurity of the second conductivity type to form a second transistor driven at a second voltage level lower than the first voltage level to adjust a threshold voltage without using additional resist (abstract).

Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to mask a portion of the several of the active regions and dope an unmasked region of the several of active regions at a second concentration higher than the first concentration with an impurity of the second conductivity type to form a second transistor driven at a second voltage level lower than the first voltage level, in Tigelaar, since, as taught by Kuroda, it will adjust a threshold voltage without using additional resist.

In re claim 2; Kuroda teaches wherein the doping step includes implanting ions of an impurity (figures 4 and 7).

In re claim 5; Tigelaar teaches wherein the step of forming the gate oxide layer, forms the gate oxide layer of the transistors driven at the first voltage and the transistors driven at the second voltage (figure 1).

In re claim 6; Tigelaar discloses wherein the gate electrode of transistors driven at the first voltage are doped at the first concentration and the gate electrode of

transistors driven at the second voltage are doped at the second concentration (column 2).

Response to Arguments

2. Applicant's arguments with respect to claims 1, 2, 5 and 6 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

3. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fernando Toledo whose telephone number is (703) 305-0567. The examiner can normally be reached on Monday - Friday, 8am - 4pm.

Application/Control Number: 09/873,580

Art Unit: 2823

Page 5

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (703) 308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Fernando Toledo	
Patent Examiner	
Art Unit 2823	

ft May 28, 2002

SUPERVICORY PRIMARY EXPANNER TECHNOLOGY CENTER 2000